EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	77	("20020020821"|"20020109823"|"20020163629"|"20030123040"|"20030174408"|"20040000627"|"20040021844"|"20040075895"|"20040109237"|"20040119954"|"20040125351"|"20050259234"|"20050264774"|"3573975"|"3648587"|"4346164"|"4390273"|"4396705"|"4480910"|"4509852"|"5040020"|"5121256"|"5610683"|"5715039"|"5825043"|"5900354"|"6191429"|"6236634"|"6560032"|"6600547"|"6603130"|"6633365"|"6665046"|"6781668"|"6788477"|"6809794"|"6867844").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 16:42
L2	1063	($4lithograph$4 or exposure) and (substrate or wafer) and (reticle or mask or pattern$4) and (projection adj3 (optical or lens or system or device or apparatus)) and ((liquid or solution or fluid or water) adj3 (supply$4 or provid$4 or inlet))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 16:56
L3	137	2 and (((((liquid or solution or fluid or water) near4 (supply$4 or provid$4)) near4 (apparatus or system or device or inlet)) same ((barrier or seal$4) adj3 (member or plate or element)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 16:50
L4	4	3 and (((outlet or discharg$4 or remov$4 or recover$4) near4 (liquid or solution or fluid or water)) near6 (radial$4 near4 outward$43) near5 (barrier))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 16:53
L5	1	(($4lithograph$4 or exposure) and (substrate or wafer) and (reticle or mask or pattern$4) and (projection adj3 (optical or lens or system or device or apparatus)) and ((liquid or solution or fluid or water) adj3 (supply$4 or provid$4 or inlet)) and (((outlet or discharg$4 or remov$4 or recover$4) near4 (liquid or solution or fluid or water)) near6 (radial$4 near4 outward$43) near5 (barrier))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 17:00

L6	7	(($4lithograph$4 or exposure) and (substrate or wafer) and (reticle or mask or pattern$4) and (projection adj3 (optical or lens or system or device or apparatus)) and ((liquid or solution or fluid or water) adj3 (supply$4 or provid$4 or inlet)) and (((outlet or discharg$4 or remov$4 or recover$4) near4 (liquid or solution or fluid or water)) near6 (radial$4 near4 outward$43) near5 (inlet or suppl$4 or provid$4))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 17:05
L7	0	(($4lithograph$4 or exposure) and (substrate or wafer) and (reticle or mask or pattern$4) and (projection adj3 (optical or lens or system or device or apparatus)) and (((liquid or solution or fluid or water) adj3 (supply$4 or provid$4 or inlet)) near5 (vibration$4 or mechanism$4) near4 (isolat$4)) and (((outlet or discharg$4 or remov$4 or recover$4) near4 (liquid or solution or fluid or water)) near6 (radial$4 near4 outward$43) near5 (inlet or suppl$4 or provid$4))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/08/06 17:06